Attorney Docket No. 071469-0305915

PATENT

Client Reference: RAJ-008

# IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of: Hideaki YAMASAKI, Tsukasa MATSUDA, Atsushi GOMI, Tatsuo

HATANO, Tatsuo HATANO, Mitsuhiro TACHIBANA, Koumei MATSUZAVA, Yumiko KAWANO, Gert J. LEUSINK, Fenton R. MCFEELY, Sandra G. MALHOTRA, Andrew H. SIMON, and John J.

YURKAS

Application No.:

Confirmation

No:

Filed:

September 30, 2003

Group No.: Examiner

For:

METHOD OF FORMING A METAL LAYER USING AN INTERMITTENT PRECURSOR

**GAS FLOW PROCESS** 

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

# APPLICATION DATA SHEET 37 C.F.R. § 1.76

#### BIBLIOGRAPHIC DATA

### 1. Applicant information

First applicant: Hideaki YAMASAKI

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Eleventh applicant: Andrew H. SIMON

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Twelfth applicant: John J. YURKAS

Citizenship: USA

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## 2. Correspondence information

Correspondence for this application should be addressed as follows:

Customer No.: 00909

## 3. Application information

Title of Invention: METHOD OF FORMING A METAL LAYER USING AN INTERMITTENT PRECURSOR GAS FLOW PROCESS

Docket number assigned to this application: 071469-0305915

Suggested Classification: Class:

Subclass:

Technology Center to which subject matter is assigned:

Total number of drawing sheets: 4

Type of application:

Utility

Application is to be published. Suggested drawing figure for publication: 1

Secrecy order under § 5.2:

This application does not disclose subject matter of an application which is under a secrecy order pursuant to § 5.2.

#### 4. Representative information

The following have a power of attorney or authorization of agent in this application:

Customer No.: 00909

# 5. Assignee information

The assignee(s) of this application is/are:

Tokyo Electron Limited 3-6, Akasaka 5-chome, Minato-ku Tokyo, 107 JAPAN Extent of interest of assignee in application: 50%

International Business Machines Corporation New Orchard Road Armonk, NY 10504 Extent of interest of assignee in application: 50%

Date: September 30, 2003

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